

CORIPIE	INFORMATION	N DISCLOSURE	STATEMENT
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IN AN APPLICATION
(Use several sheets if necessary)

Docket Number: 30874.101USU1 Application Number:

09/815,746

Applicant: Sining Mao

Filing Date: March 23, 2001

Group Art Unit: 2652

				U.S. PATENT DOCUMENT	ГS					
EXAMINER INITIAL	DOCUMENT NO.		DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE			
AC	5,018,037		05/21/1991	Krounbi et al.						
K	5,666,246		09/09/1997	Gill et al.						
se	5,920,446		07/06/1999	Gill			EWED			
K	6,134,090		10/17/2000	Mao et al.		-BEC	EIVED			
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			FC	DREIGN PATENT DOCUM	ENTS	16CIIII010	9,-			
	DOCUMENT NO.		DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION			
							YES	NO		
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		ОТН	ER DOCUMEN	TS (Including Author, Title, E	Date, Pertinent Pag	es, Etc.)				
Ac		Belleson, Jim, and Ed Grochowski; The Era of Giant Magnetoresistive Heads: IBM's Magnetoresistive and Giant Magnetoresistive Head Technologies Enable Data Storage Products with the Industry's Highest Areal Densities; http://www.storage.ibm.com.								
k k		Fernandez-de-Castro, Juan J., Russell J. Machelski, L. G. Swanson and G. S. Mowry; Permanent Magnet Stabilization of an Overlaid MR Head; IEEE Transactions on Magnetics, September 1996, Volume 32, Number 5.								
K		Zhu, Jian-Gang and Daniel J. O'Connor; Impact of microstructure on Stability of Permanent Magnet Biased Magnetoresistive Heads; IEEE Transactions on Magnetics, January 1996, Volume 32, Number 1.								
K		Sharma, N., G. A. Jones, S. M. Casey and P. J. Grundy; The Microstructure and Magnetic Properties of Cobalt-Rich Co-Pt Alloy Thin Films Grown Using Ion-Beam-Assisted Deposition; Journal of Physics D: Applied Physics, Volume 31, Number 7 November 1998.								

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PATENT TRADEMARK OFFICE

EXAMINER Men lus

DATE CONSIDERED

10/30/03

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.